



Leica TCS SMD Series

Single Molecule Detection Platform

Technical Documentation

Living up to Life

Leica
MICROSYSTEMS

General Specifications of SMD Prepared Leica TCS SP5

| | | |
|--|---------------------------|---|
| Microscopes | Upright | Leica DM6000 CS |
| | | Leica DM6000 CFS |
| | Inverted | Leica DMI6000 CS |
| | | Leica DMI6000 CS bottom port |
| Microscope anti-vibration table | Specification | For imaging |
| | Vibration insulation | Passive |
| Z-drive | SuperZ galvanometer stage | 1500 µm travel range/3 nm stepsize |
| | Motorfocus (stand) | Travel range depending on mechanics of microscope/15 nm step size |
| Continuous wave lasers | Laser type | For imaging |
| | VIS | Diode, 40 mW: 442 nm |
| | | Ar, 65 mW: 458, 476, 488, 496, 514 nm |
| | | HeNe, 1 mW: 543 nm |
| | | HeNe, 2 mW: 594 nm |
| | | HeNe, 10 mW: 633 nm |
| | | DPSS, 20 mW: 561 nm |
| | UV | Diode, 50 mW: 405 nm |
| Pulsed lasers | Laser type | For imaging |
| | IR | TiSa 1.2 ps 1 W 690...1040 nm (various ranges) |
| | VIS | — |
| | | — |
| | UV | — |
| Excitation modulation | Modulation type | For imaging |
| | AOTF VIS | Up to 8 channels |
| | AOTF UV | Up to 3 channels |
| | EOM IR | Yes |
| | Pulsed laser driver | Optional |

| Additional SMD Specific Specifications | | | |
|--|---|--|--|
| | TCS SMD FCS | TCS SMD FLIM | TCS SMD FLCS |
| | Yes | Yes | Yes |
| | Yes | Yes | Yes |
| | Yes, recommended | Yes | Yes, recommended |
| | Yes | Yes | Yes |
| | For FCS | For FLIM | For FCS and FLIM |
| | Passive | Passive | Passive |
| | 1500 µm travel range/3 nm stepsize | 1500 µm travel range/3 nm stepsize | 1500 µm travel range/3 nm stepsize |
| | Travel range depending on mechanics of microscope/15 nm step size | Travel range depending on mechanics of microscope/15 nm step size | Travel range depending on mechanics of microscope/15 nm step size |
| | For FCS | No cw laser excitation for FLIM | For FCS |
| | Diode, 40 mW: 442 nm | — | Diode, 40 mW: 442 nm |
| | Ar, 65 mW: 458, 476, 488, 496, 514 nm | — | Ar, 65 mW: 458, 476, 488, 496, 514 nm |
| | HeNe, 1 mW: 543 nm | — | HeNe, 1 mW: 543 nm |
| | HeNe, 2 mW: 594 nm | — | HeNe, 2 mW: 594 nm |
| | HeNe, 10 mW: 633 nm | — | HeNe, 10 mW: 633 nm |
| | DPSS, 20 mW: 561 nm | — | DPSS, 20 mW: 561 nm |
| | — | — | — |
| | Pulsed excitation for FCS not required | For FLIM | For FLIM and FLCS |
| | — | TiSa 1.2 ps 1 W 680 ... 1040 nm (various ranges) | TiSa 1.2ps 1 W 680 ... 1040 nm (various ranges) |
| | — | Diode, up to 3 mW average @ 40 MHz, 470 nm (software controlled selection of pulse frequency: 5, 10, 20, 40 MHz), < 90 ps ... < 500 ps (depending on selected power level) | Diode, up to 3 mW average @ 40 MHz, 470 nm (software controlled selection of pulse frequency: 5, 10, 20, 40 MHz), < 90 ps ... < 500 ps (depending on selected power level) |
| | — | Diode, up to 4.5 mW average @ 40 MHz, 640 nm (software controlled selection of pulse frequency: 5, 10, 20, 40 MHz), < 90 ps ... < 400 ps (depending on selected power level) | Diode, up to 4.5 mW average @ 40 MHz, 640 nm (software controlled selection of pulse frequency: 5, 10, 20, 40 MHz), < 90 ps ... < 400 ps (depending on selected power level) |
| | — | Diode, up to 3 mW average @ 40 MHz, 405 nm (software controlled selection of pulse frequency: 5, 10, 20, 40 MHz), < 70 ps ... < 300 ps (depending on selected power level) | Diode, up to 3 mW average @ 40 MHz, 405 nm (software controlled selection of pulse frequency: 5, 10, 20, 40 MHz), < 70 ps ... < 300 ps (depending on selected power level) |
| | For FCS | For FLIM | For FCS and FLIM |
| | Up to 8 channels | — | For FCS: 8 channels |
| | — | — | — |
| | — | Optional for MP FLIM | Optional for MP FLIM |
| | — | For VIS and UV FLIM: up to 3 channels | For VIS and UV FLIM: up to 3 channels |

General Specifications of SMD Prepared Leica TCS SP5

| | | |
|----------------|--|--|
| Optics | Features | For imaging |
| | Number of laser ports | Up to 3 (UV - VIS - IR) |
| | Number of lasers | Up to 8 |
| | Excitation – emission splitting | Acousto Optical Beam Splitter (AOBS®) or dichroic beam splitters |
| | Detection range | 400...800 nm |
| | UV and IR imaging | Sequential or simultaneous |
| | Field upgradable | To IR: yes |
| | UV correction | Individual precise correction optics (up to 6 positions) |
| | Pinhole | Alignment stable single pinhole |
| | Pinhole diameter control | Motorized by software, automatic mode available |
| Scanner | Scanner design | For imaging |
| | Scanning concept | Optically correct scanning at low inertia |
| | Switch conventional – resonant scanner | Conventional and resonant scanner in one system (optional) |
| | Conventional scanner | For imaging (PMT and APD) |
| | Maximal line frequency | 2800 Hz |
| | Minimal line frequency | 1 Hz |
| | Scan speed granulation | 1400 |
| | Maximal frame rate 512 x 512 | 5 Hz |
| | Maximal frame rate 512 x 16 | 50 Hz |
| | Beam park | Yes |
| | Maximal frame resolution | 8192 x 8192 pixel |
| | Scan zoom | 1.0 ... 64 x |
| | Panning | Yes |
| | Field rotation | 200° optical |
| | Field diameter | 22 mm |

| Additional SMD Specific Specifications | | | |
|--|--|--|---|
| TCS SMD FCS | | TCS SMD FLIM | TCS SMD FLCS |
| For FCS | | For FLIM | For FCS and FLIM |
| 1 (VIS) | | 2 (UV & IR, or UV & VIS) | For FCS: 1 (VIS) For FLIM: 2 (UV & IR, or UV & VIS) |
| Up to 8 | | Up to 3 | For FCS: up to 8, For FLIM: up to 3 |
| AOBS | | For pulsed lasers: dichroic mirrors | For FCS: AOBS, For pulsed lasers: dichroic mirrors |
| Depending on filter cube used | | Internal SP FLIM: 400 ... 800 nm External FLIM: Depending on filter cube used | Depending on filter cube used |
| – | | – | Internal SP FLIM: 400 ... 800 nm External FLIM, FCS, and FLCS: Depending on filter cube used |
| To FCS: yes | | To FLIM: yes | – |
| UV not required for FCS | | Required for UV FLIM | To FLCS: yes |
| Alignment stable single pinhole | | Alignment stable single pinhole | Required for UV FLIM |
| Motorized by software, automatic mode available | | Motorized by software, automatic mode available | Alignment stable single pinhole |
| For FCS | | For FLIM | For FCS and FLIM |
| Beam park | | Optically correct scanning at low inertia | FCS: Beam park FLIM: optically correct scanning at low inertia |
| Conventional scanner required | | Conventional and resonant scanner in one system (optional) | Conventional scanner required, resonant scanner optional |
| No scanning during FCS measurement | | For FLIM data acquisition | For FLIM data acquisition |
| – | | 1400 Hz | 1400 Hz |
| – | | 1 Hz | 1 Hz |
| – | | 1400 | 1400 |
| – | | 5 Hz | 5 Hz |
| – | | 50 Hz | 50 Hz |
| – | | Yes | Yes |
| – | | 512 x 512 pixel | 512 x 512 pixel |
| – | | 1.0 ... 64 x | 1.0 ... 64 x |
| – | | no | no |
| – | | 200° optical | 200° optical |
| – | | 22 mm | 22 mm |

General Specifications of SMD Prepared Leica TCS SP5

| | | |
|------------------------------|--|--|
| Scanner | Resonant scanner | For imaging |
| | Maximal line frequency | 16000 Hz |
| | Minimal line frequency | 8000 Hz |
| | Scan speed granulation | 1 |
| | Maximal frame rate 512 x 512 | 28 Hz |
| | Maximal frame rate 512 x 16 | 290 Hz |
| | Beam park | No |
| | Maximal frame resolution | 1024 x 1024 pixel |
| | Scan zoom | 1.7 ... 64 x |
| | Panning | Yes |
| | Field rotation | 200° optical |
| | Field diameter | 15 mm |
| Scan modes | Scan options | For imaging |
| | xt | Yes |
| | xy | Yes |
| | xyt | Yes |
| | xyλ | Yes |
| | xz | Yes |
| | xzλ | Yes |
| | xyz | Yes |
| | xyzλ | Yes |
| | xyt | Yes |
| | xzt | Yes |
| | xyzt | Yes |
| | xytz | Yes |
| | Automated brightness control of FLIM images | – |
| | Maximum number of FLIM images | – |
| Beam park positioning | Beam park options | For spot bleach (in general software) |
| | xy | Yes |
| | xyz | No |
| | xz | No |
| | xzy | No |
| | Maximum number of FCS/FLCS measurements | – |
| | Maximum number of distinct measurement points | – |
| | Maximum number of measurement repetitions at a point | – |
| | Maximum number of measurement cycles | – |

| | Additional SMD Specific Specifications | | |
|--|---|---|---|
| | TCS SMD FCS | TCS SMD FLIM | TCS SMD FLCS |
| | No scanning during FCS measurement | For FLIM data acquisition | For FLIM data acquisition |
| | – | 8000 Hz | 8000 Hz |
| | – | 8000 Hz | 8000 Hz |
| | – | 1 | 1 |
| | – | 28 Hz | 28 Hz |
| | – | 290 Hz | 290 Hz |
| | – | No | No |
| | – | 512 x 512 pixel | 512 x 512 pixel |
| | – | 1.7 ... 64 x | 1.7 ... 64 x |
| | – | No | No |
| | – | 200° optical | 200° optical |
| | – | 15 mm | 15 mm |
| | No scanning during FCS measurement | For FLIM data acquisition | For FLIM data acquisition |
| | – | No | No |
| | – | Yes | Yes |
| | – | Yes | Yes |
| | – | Yes (SP FLIM) | Yes (SP FLIM) |
| | – | Yes | Yes |
| | – | Yes (SP FLIM) | Yes (SP FLIM) |
| | – | Yes | Yes |
| | – | Yes (SP FLIM) | Yes (SP FLIM) |
| | – | Yes | Yes |
| | – | Yes | Yes |
| | – | Yes | Yes |
| | – | No | No |
| | – | Yes | Yes |
| | – | 1000 | 1000 |
| | For automated FCS, FCCS, FLCS data acquisition series (in FCS wizard) | For single point lifetime measurement (in general software) | For automated FCS, FCCS, FLCS data acquisition series (in FCS wizard) |
| | Yes | Yes | Yes |
| | Yes | No | Yes |
| | Yes | No | Yes |
| | Yes | No | Yes |
| | 1000 | – | 1000 |
| | 100 | – | 100 |
| | 100 | – | 100 |
| | 100 | – | 100 |

General Specifications of SMD Prepared Leica TCS SP5

| | | |
|------------------------------------|--|---|
| Internal confocal detection | Detection features | Up to 5 PMT for confocal imaging |
| | Emission separation | Highly sensitive prism spectral detector |
| | Maximum number of confocal channels | 5 |
| | Tunability of emission bands | Yes |
| | Spectral detection range | 400 – 800 nm |
| | Tuning steps of emission bands | 1 nm |
| | Minimal detection range | 5 nm |
| | Sensors | High sensitivity low noise PMT: R 9624 |
| | Dark current | – |
| | TTS FWHM | – |
| External confocal detection | Detection features | 2 APDs for confocal imaging |
| | Emission separation | User-exchangeable beam splitting filter cubes |
| | Confocal channels | 2 |
| | Sensors | APDs from PE (SPCM-AQRH series) or MPD (PDM series) |
| | Quantum efficiency | PE APD: wavelength dependent, typ. 65% @ 670 nm MPD APD: wavelength dependent, typ. 45% @ 550 nm |
| | Dark counts | PE APD: < 250 cps MPD APD: < 250 cps |
| | Jitter FWHM | Not relevant |
| | Dead time | Not relevant |
| Non-confocal detection | Detection types | For Imaging |
| | Transmitted light detector | Optional, allowing BF, DIC, Ph etc. |
| | Non descanned transmitted light channels | Up to 4 channels (MP) |
| | Non descanned reflected light channels | Up to 4 channels (MP) |
| Electronics | Devices | For imaging |
| | Scanner control | Digitally at high performance (FPGA, field programmable gate arrays) |
| | Trigger in/out functions | Yes |
| | Auxiliary data input channels | Up to 2 |
| | Max channels in parallel | 12 |
| | Computer | High performance PC workstation |
| | Integration of third party software | – |
| | – | Programmable control panel with LCD function & value display |

| Additional SMD Specific Specifications | | | |
|---|--|---|---|
| TCS SMD FCS | | TCS SMD FLIM | TCS SMD FLCS |
| Not for FCS data acquisition | | Up to 2 FLIM-PMTs for spectral FLIM | Up to 2 FLIM-PMTs for spectral FLIM |
| – | | Highly sensitive prism spectral detector | Highly sensitive prism spectral detector |
| – | | 2 for FLIM + 3 for imaging | 2 for FLIM + 3 for imaging |
| – | | Yes | Yes |
| – | | 400 – 800 nm | 400 – 800 nm |
| – | | 1 nm | 1 nm |
| – | | 5 nm | 5 nm |
| – | | SP FLIM PMT (Hamamatsu R7400U series, active cooled) | SP FLIM PMT (Hamamatsu R7400U series, active cooled) |
| – | | < 300 cps @ 15 °C | < 300 cps @ 15 °C |
| – | | MP FLIM: < 300 ps UV & VIS FLIM: < 400 ps | MP FLIM: < 300 ps UV & VIS FLIM: < 400 ps |
| 2 external detectors for FCS & FCCS | | 2 external detectors for FLIM | 2 external detectors for FCS, FCCS, FLCS, and FLIM |
| User-exchangeable beam splitting filter cubes | | User-exchangeable beam splitting filter cubes | User-exchangeable beam splitting filter cubes |
| 2 | | 2 | 2 |
| APDs from PE (SPCM-AQRH series) or MPD (PDM series) | | APDs from MPD (PDM series) | APDs from MPD (PDM series) |
| PE APD: wavelength dependent, typ. 65% @ 670 nm MPD APD: wavelength dependent, typ. 45% @ 550 nm | | Wavelength dependent, typ. 45% @ 550 nm | Wavelength dependent, typ. 45% @ 550 nm |
| PE APD: < 250 cps MPD APD: < 250 cps | | MPD APD: < 250 cps | MPD APD: < 250 cps |
| Not relevant | | MPD APD: 400 – 500 nm: typ. 200 ps > 500 nm: down to 50 ps | MPD APD: 400 – 500 nm: typ. 200 ps > 500 nm: down to 50 ps |
| Below typical count rate (40 ... 70 ns) | | Below typical count rate (40 ... 70 ns) | Below typical count rate (40 ... 70 ns) |
| None for FCS | | None for FLIM | None for FLIM and FCS |
| – | | – | – |
| – | | – | – |
| – | | – | – |
| For FCS | | For FLIM | For FCS and FLIM |
| Digitally at high performance (FPGA, field programmable gate arrays) | | Digitally at high performance (FPGA, field programmable gate arrays) | Digitally at high performance (FPGA, field programmable gate arrays) |
| Not required | | Required | Required |
| Used for APD imaging | | Optional: Used for APD imaging | Used for APD imaging |
| 12 | | 12 | 15 |
| Second workstation for FCS data acquisition and analysis | | Second workstation for FLIM data acquisition and analysis | Second workstation for FCS and FLIM data acquisition and analysis |
| Client server network connection between workstations for full system control and data transfer | | Client server network connection between workstations for full system control and data transfer | Client server network connection between workstations for full system control and data transfer |
| Required | | Required | Required |

General Specifications of SMD Prepared Leica TCS SP5

| | | |
|----------------------------------|--|--|
| Extensions | Devices | For imaging |
| | Fast ROI-spectrometer | Optional |
| | Auxiliary emission port | Optional |
| | Environment accessories | Various options |
| Software (LAS AF) | General | Intuitive and guiding user interface |
| | Context sensitive online help system | Included |
| | Multi-dimensional data acquisition | Included |
| | Region of interest (ROI) scan | Included |
| | Excitation line/frame sequential scan | Included |
| | Emission spectrum recording | Included |
| | Quantification tools | Included |
| | Multi-color restoration, spectral unmixing | Included |
| | General time lapse experiment control tile scanning (mosaic scan) | Included |
| Software options (LAS AF) | Dedicated application wizards | For imaging |
| | Live Data Mode | Interactive data recording also allowing job sequencing and online evaluation |
| | Advanced Mark & Find | Combines Mark & Find with sophisticated 3D recordings, Live Data Mode etc. |
| | 3D visualization | Maximum and other projections, simulated fluorescence process, rotation animations, stereo pairs, red-green anaglyphs, height color coded extended depth of focus images etc. |
| | Colocalization | Histogram based colocalization and area measurements |
| | Deconvolution | Deconvolution option for widefield and confocal images |
| | MicroLab | FRAP wizard, FRAPxt wizard, FLIP wizard, FRET SE wizard, FRET AB wizard etc. |
| | SMD FCS wizard | — |
| | SMD FLIM wizard | — |

| | Additional SMD Specific Specifications | | |
|--|---|--|--|
| | TCS SMD FCS | TCS SMD FLIM | TCS SMD FLCS |
| | For FCS | For FLIM | For FCS and FLIM |
| | Not possible | Optional with internal SP FLIM Not possible with external FLIM | Not possible |
| | Not possible | Optional with internal SP FLIM Not possible with external FLIM | Not possible |
| | Various options | Various options various options | Various options |
| | Included | Included | Included |
| | Included | Included | Included |
| | Included | Included | Included |
| | included | included | included |
| | Included | Included | Included |
| | Included | Included | Included |
| | Included | Included | Included |
| | Included | Included | Included |
| | Included | Included | Included |
| | For FCS/FCCS | For FLIM | For FCS/FCCS/FLCS and for FLIM |
| | – | – | – |
| | – | – | – |
| | – | – | – |
| | – | – | – |
| | – | – | – |
| | – | – | – |
| | FCS wizard for optimization and automation of FCS and FCCS measurement series | – | FCS wizard for optimization and automation of FCS, FCCS and FLCS measurement series |
| | – | FLIM wizard for optimization and automation of FLIM measurement stacks and time series | FLIM wizard for optimization and automation of FLIM measurement stacks and time series |

General Specifications of SMD Prepared Leica TCS SP5

| Software features SymphoTime | General | For imaging |
|------------------------------|---|-------------|
| | Supported time-resolved analysis methods | – |
| | One-line visualization for time-resolved data acquisition | – |
| | FLIM/FCS options | For imaging |
| | Data acquisition method | – |
| | TCSPC channel width | – |
| | Resolvable lifetime range | – |
| | FLIM analysis | For imaging |
| | Data processing | – |
| | Fitting models | – |
| | Optimization methods | – |
| | Error test/assessment | – |
| | Error analysis | – |
| | FCS analysis | For imaging |
| | Correlation method | – |
| | Fitting model | – |
| | Optimization methods | – |
| | Error test/assessment | – |
| | Error analysis | – |

| Additional SMD Specific Specifications | | | |
|---|--|--|--|
| TCS SMD FCS | | TCS SMD FLIM | TCS SMD FLCS |
| For FCS/FCCS | | For FLIM | For FCS/FCCS/FLCS and for FLIM |
| FCS, FCCS, FRET, Scripting language for user-defined analysis routines | | FLIM, FLIM-FRET, Lifetime Histogram, Scripting language for user-defined analysis routines | FLIM, FLIM-FRET, FCS, FCCS, FLCS, FRET, Lifetime Histogram, Fluorescence Time/Lifetime Traces, Scripting language for user-defined analysis routines |
| Auto- or Crosscorrelation, Intensity time-trace | | FLIM image, Intensity-time trace, TCSPC histogram | Auto- or Crosscorrelation, FLIM image, Intensity-time trace, TCSPC histogram |
| For FCS/FCCS | | For FLIM | For FCS/FCCS/FLCS and for FLIM |
| Time-Tagging of photon arrival times using Time-Correlated Single Photon Counting (TCSPC) electronics | | Time-Correlated Single Photon Counting (TCSPC) | Time-Correlated Single Photon Counting (TCSPC) |
| – | | min. 4 ps | min. 4 ps |
| – | | < 100 ps to some μ s (depending on system configuration and experimental conditions) | < 100 ps to some μ s (depending on system configuration and experimental conditions) |
| For FCS/FCCS | | For FLIM | For FCS/FCCS/FLCS and for FLIM |
| – | | Whole image or ROIs (arbitrary shape) | Whole image or ROIs (arbitrary shape) |
| – | | 1 to 4 exponentials, iterative reconvolution or tail fitting | 1 to 4 exponentials, iterative reconvolution or tail fitting |
| – | | Least squares, MLE, Marquardt-Levenberg, Monto Carlo | Least squares, MLE, Marquardt-Levenberg, Monto Carlo |
| – | | Chi-Square, distribution weighted residuals | Chi-Square, distribution weighted residuals |
| – | | Asymptotic standard errors | Asymptotic standard errors |
| For FCS/FCCS | | For FLIM | For FCS/FCCS/FLCS and for FLIM |
| Software correlation (auto- and crosscorrelation) | | – | Software correlation (auto- and crosscorrelation) |
| Pure diffusion, triplet-state, conformational, protonation, 2D/3D Gaussian PSF | | – | Pure diffusion, triplet-state, conformational, protonation, 2D/3D Gaussian PSF |
| Least squares, Marquardt-Levenberg, Monto Carlo | | – | Least squares, Marquardt-Levenberg, Monto Carlo |
| Chi-Square, distribution weighted residuals | | – | Chi-Square, distribution weighted residuals |
| Asymptotic standard errors, bootstrap and support plane analysis | | – | Asymptotic standard errors, bootstrap and support plane analysis |

Installation Requirements

| | | |
|---------------------------|--|--|
| Weight base system | VIS | Max. 320 kg |
| | IR | Optical bench 900 x 1500 mm: + ca. 280 kg IR laser system: + ca. 100 kg |
| | SMD specific components | + up to 160 kg |
| Heat load max. | VIS | 3.2 kW |
| | IR | 6.2 kW |
| Separate cooling | IR laser | IR laser, air-cooled heat exchanger (chiller) |
| Electric supply | VIS lasers (with or without 405 nm cw laser) | 3 x 100 ... 120 or 200 ... 240 V AC. 1600 VA, 50/60 Hz |
| | IR laser | +1x 100 ... 120 or 200 ... 240 V AC, 15 ... 10 A, 50/60 Hz |
| | Chiller for IR laser | +1x 100 ... 120 or 200 ... 240 V AC, 10 A/6 A, 50/60 Hz |
| | SMD | +1x 100 ... 120 or 200 ... 240 V AC, 20 A/16 A, 50/60 Hz |
| Environment | Room temperature | +18 to + 25°C, avoid proximity to air conditioning equipment! |
| | Temperature for optimal optical behavior | +21 to + 23 °C |
| | Vibration velocity @ Frequency range 5 Hz–30 Hz @ Frequency range 5 Hz–30 Hz | < 30 µm/s (effective value) < 60 µm/s (effective value) |
| | Pollution degree | Class 2, protect from dust! |
| | Relative humidity | 20 – 80% (not condensing) |
| | Illumination | Room darkening recommended! |
| | Load carrying capacity | 200 kg/m ² |
| | Door width | > 1.00 m |



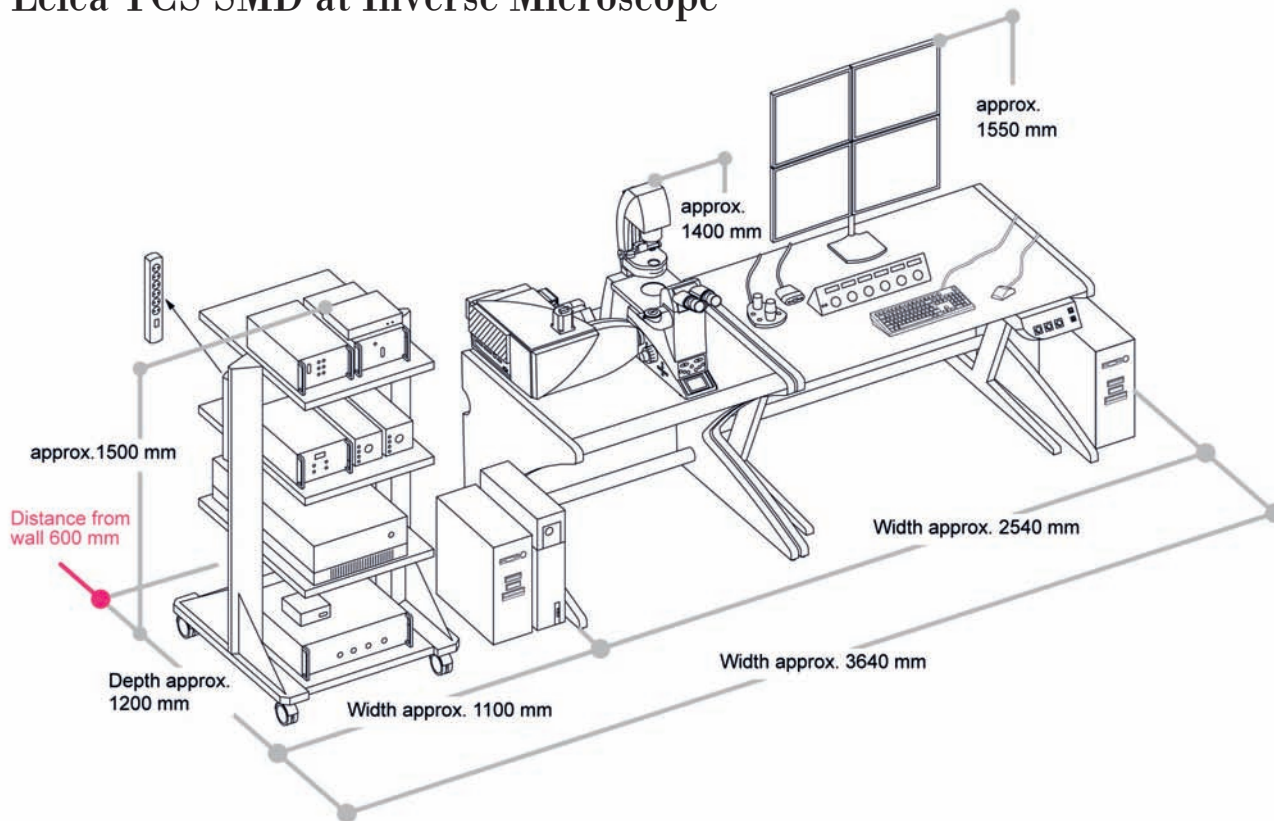
visible and ultraviolet radiation:



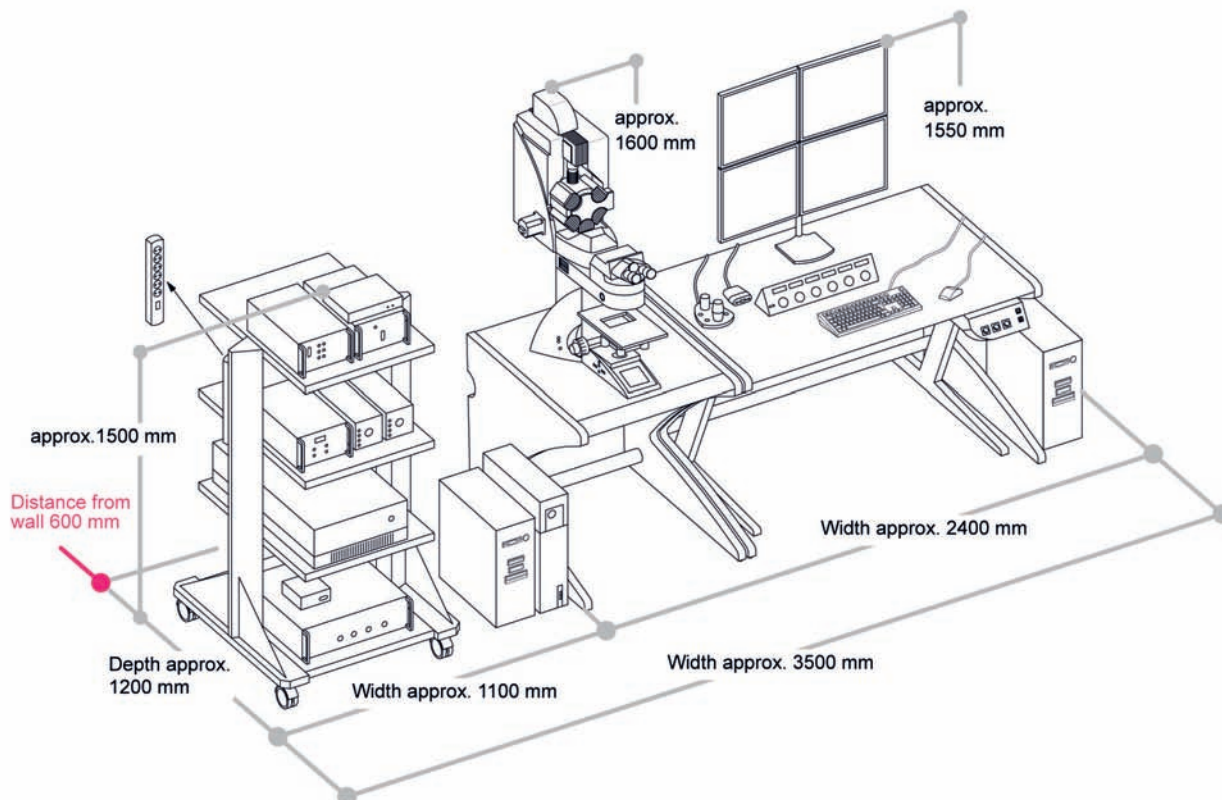
infrared radiation:



Leica TCS SMD at Inverse Microscope



Leica TCS SMD at Upright Microscope



“With the user, for the user”

Leica Microsystems

Leica Microsystems operates globally in four divisions, where we rank with the market leaders.

• Life Science Division

The Leica Microsystems Life Science Division supports the imaging needs of the scientific community with advanced innovation and technical expertise for the visualization, measurement, and analysis of microstructures. Our strong focus on understanding scientific applications puts Leica Microsystems' customers at the leading edge of science.

• Industry Division

The Leica Microsystems Industry Division's focus is to support customers' pursuit of the highest quality end result. Leica Microsystems provide the best and most innovative imaging systems to see, measure, and analyze the microstructures in routine and research industrial applications, materials science, quality control, forensic science investigation, and educational applications.

• Biosystems Division

The Leica Microsystems Biosystems Division brings histopathology labs and researchers the highest-quality, most comprehensive product range. From patient to pathologist, the range includes the ideal product for each histology step and high-productivity workflow solutions for the entire lab. With complete histology systems featuring innovative automation and Novocastra™ reagents, Leica Microsystems creates better patient care through rapid turnaround, diagnostic confidence, and close customer collaboration.

• Surgical Division

The Leica Microsystems Surgical Division's focus is to partner with and support surgeons and their care of patients with the highest-quality, most innovative surgical microscope technology today and into the future.

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